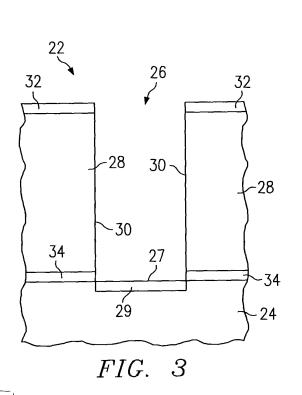
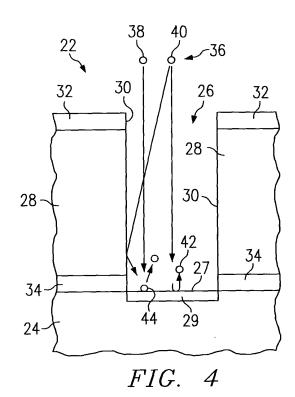


FIG. 2 (PRIOR ART)







PLASMA POWER (W)	ETCH RATE (Å/min)	
500	23	
700	21	
900	18	

FIG. 5

TEST	RF BIAS (W)	ETCH CHEMISTRY (sccm)	ETCH RATE (Å/min)
Α	0	Ar ONLY: 120	46
В	300	Ar ONLY: 120	660
С	0	N2 ONLY: 100	454
D	300	N2 ONLY: 100	3068
E	0	Ar/N2: 100/20	322
F	100	Ar/N2: 100/20	1280
G	300	Ar/N2: 100/20	2712
Н	500	Ar/N2: 100/20	3474

FIG. 6